

Threshold voltage of MOS transistor:

- The threshold voltage of a MOS transistor (V_{th} is V_{GS} required to strongly invert the surface of the substrate under the gate.) is calculated like that of a MOS structure with one slight modification in Q_B .

$$Q_B = \sqrt{2q N_{sub} \epsilon_{sub} |2\phi_F - V_{SB}|}$$

Where V_{SB} is the source to bulk voltage.

- For circuit analysis:

$$V_{th} = V_{T0} + \gamma(\sqrt{|2\phi_F - V_{SB}|} - \sqrt{|2\phi_F|})$$

Where γ is called body effect coefficient = $\frac{\sqrt{2q N_{sub} \epsilon_{sub}}}{C_{ox}}$

V_{T0} = the threshold voltage with $V_{SB} = 0$ i.e. with out the body effect.

Depletion mode Versus Enhancement mode MOSFET:

- If a MOSFET is on (i.e. in strong inversion) at zero bias then it is a depletion Mode MOSFET (it is normally ON).
 - We actually have to apply a $V_{GS} < V_{th}$ to turn off the NMOS or a $V_{GS} > V_{th}$ for PMOS .
- If a MOSFET is normally off \rightarrow it is enhancement mode
 - Then for NMOS we have to apply a $V_{GS} > V_{th}$ to turn it ON or a $V_{GS} < V_{th}$ to turn a PMOS ON.

Depletion NMOS $\rightarrow V_{th} \leq 0$
Depletion PMOS $\rightarrow V_{th} \geq 0$

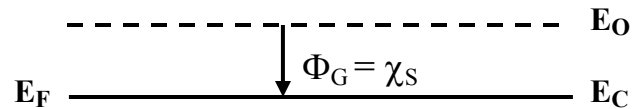
Enhancement NMOS $\rightarrow V_{th} > 0$
Enhancement PMOS $\rightarrow V_{th} < 0$

Poly Gate MOSFET:

The gate of MOS transistors is usually made with polycrystalline Si, that is heavily doped (either P or N type).

- In this case Φ_G depends on the type of poly Si
- For N-type poly \rightarrow the Fermi level is in the conduction band \rightarrow

$$\Phi_G = E_O - E_F = \chi_s$$



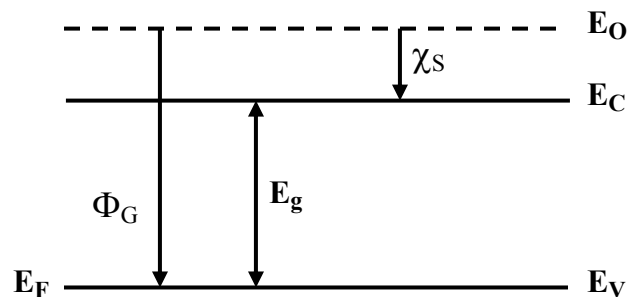
The flat-band voltage V_{FB} :

$$V_{FB} = \Phi_G - \Phi_S = \chi_s - \left[\chi_s + \frac{E_g}{2q} - \phi_F \right] \rightarrow$$

$$V_{FB} = -\frac{E_g}{2q} + \phi_F$$

- For P-type poly \rightarrow the Fermi level is in the Valence band \rightarrow

$$\Phi_G = E_O - E_F = \chi_s + E_g$$



Hence:

$$V_{FB} = \chi_s + \frac{E_g}{2q} - \left[\chi_s - \frac{E_g}{2q} - \phi_F \right] \rightarrow$$

$$V_{FB} = \frac{E_g}{2q} + \phi_F$$

Ex1) An MOS transistor is made with a P-type substrate ($N_a = 10^{16} \text{ cm}^{-3}$) and a heavily doped P-type poly Si gate.
 $C_{ox} = 2 \text{ fF}/\mu\text{m}^2$. Calculate V_{th} and specify the type of the transistor

Sol:

This is an NMOS transistor, since the type of substrate is p-type .

$$V_{th} = V_{FB} + 2\phi_F - \frac{Q_B}{C_{OX}} - \frac{Q_{OX}}{C_{OX}}$$

$$\phi_F = -V_T \ln \frac{N_a}{n_i} = -0.025 \ln \frac{10^{16}}{10^{10}} = -0.345$$

$$V_{FB} = \Phi_G - \Phi_S = \chi_s + E_g - \left[\chi_s + \frac{E_g}{2q} - \phi_F \right]$$

$$= -0.345 + 0.55 = 0.19 \text{ v}$$

$$Q_B = \sqrt{2q N_{sub} \epsilon_{sub} |2\phi_F|} = \sqrt{1.6 \times 10^{-19} \times 2 \times 10^{16} \times 8.85 \times 10^{-14} \times 12}$$

$$= -4.8 \times 10^{-8} \text{ c/cm}^2$$

$$V_{th} = 0.19 + 0.69 + 4.8 \times 10^{-8} = 1.12 \text{ V}$$

→ the type is enhancement NMOS

Ex2) For the same transistor in [Ex1], if the Gate poly is N-type & $Q_{ox} = 5 \times 10^{-8} \text{ c/cm}^2$ Calculate V_{th} and specify the type of the transistor
 Sol:

$$\phi_F = -0.345 \text{ v},$$

$$V_{FB} = \chi_s - \left[\chi_s + \frac{E_g}{2q} - \phi_F \right]$$

$$V_{FB} = -0.89 \text{ V}, \quad Q_B \text{ is the same.}$$

→

$$V_{th} = -0.89 + 0.69 + \frac{4.8 \times 10^{-8}}{2 \times 10^{-7}} - \frac{5 \times 10^{-8}}{2 \times 10^{-7}} \approx -0.21 \text{ v}$$

→ the type is Depletion NMOS

Ex3)

For example 2, what is the type of the doping and its concentration required to make $V_{th} = +0.8 \text{ v}$?

Sol.:

We want to increase V_{th} by about 1v (i.e. make it harder to invert

→ we need to make it more P-type => i.e. increase N_a

- By how much should we increase N_a ?

N_a affects ϕ_F : $|\phi_F| \propto \ln N_a$

N_a also affects V_{FB} : $V_{FB} \propto \ln N_a$

N_a affects $Q_B \propto \sqrt{N_a}$. This is a bigger dependency

Ignore effects of N_a on ϕ_F and V_{FB} =>

we need to increase $\frac{Q_B}{C_{OX}}$ by 1 volt

$\frac{Q_B}{C_{OX}}$ was $\approx 0.23 \text{ v}$

we need it to be $= 1.23 \text{ v}$ →

$$Q_B = 1.23 C_{ox} = 2.46 \times 10^{-7} \text{ c/cm}^2$$

$$= \sqrt{2 q N_{sub} \epsilon_{sub} |2 \phi_F|} = Na = 2.58 \times 10^{17} \text{ c/cm}^2$$

we already have $10^{16} \Rightarrow$ we need to add $2.58 \times 10^{17} - 10^{16} = 2.48 \times 10^{16} \text{ cm}^{-3}$
more acceptors.